



Alexander Hirler (Autor)

## New Approaches to Reliability Qualification of Semiconductor Components under Varying and Progressive Stresses

Alexander Hirler



New Approaches to Reliability Qualification  
of Semiconductor Components  
under Varying and Progressive Stresses



Cuvillier Verlag Göttingen  
Internationaler wissenschaftlicher Fachverlag

<https://cuvillier.de/de/shop/publications/8542>

### Copyright:

Cuvillier Verlag, Inhaberin Annette Jentzsch-Cuvillier, Nonnenstieg 8, 37075 Göttingen,  
Germany

Telefon: +49 (0)551 54724-0, E-Mail: [info@cuvillier.de](mailto:info@cuvillier.de), Website: <https://cuvillier.de>

# Contents

<b>1</b>	<b>Introduction</b>	<b>1</b>
<b>2</b>	<b>Theory of Reliability Testing</b>	<b>3</b>
2.1	Statistical Description of Failures . . . . .	3
2.1.1	Basic Concepts of Failure Statistics . . . . .	3
2.1.2	The Bathtub Curve . . . . .	6
2.1.3	Failure Distributions . . . . .	7
2.1.4	Visualization and Analysis . . . . .	11
2.2	Reliability Methodology . . . . .	27
2.2.1	Reliability Testing and Lifetime Predictions . . . . .	27
2.2.2	Accelerated Lifetime Testing . . . . .	29
2.2.3	Data Analysis and Evaluation . . . . .	33
<b>3</b>	<b>The Failure Mechanism of Time-Dependent Dielectric Breakdown</b>	<b>37</b>
3.1	Physics of Dielectric Breakdown . . . . .	37
3.2	Test Structures, Devices and Methodology . . . . .	40
3.3	Failure Acceleration . . . . .	46
<b>4</b>	<b>Effective Stressors</b>	<b>61</b>
4.1	Mission Profiles . . . . .	61
4.2	Cumulative Damage Models . . . . .	63
4.2.1	Cumulative Exposure Model . . . . .	63
4.2.2	Tampered Random Variable Model . . . . .	65
4.2.3	Tampered Failure Rate Model . . . . .	67
4.2.4	Experimental Validation of Cumulative Damage Behavior . . . . .	70
4.2.5	Model Comparison . . . . .	74
4.3	Mission Profile Stress and Effective Stressors . . . . .	78
4.3.1	Transformation of Step-Stress into Effective Stress . . . . .	80
4.3.2	Experimental Validation of the Effective Stress Transformation . . . . .	82

4.4	Multi-Dimensional Mission Profiles with Interdependent Stressors . . . . .	90
4.4.1	Multi-Dimensional Acceleration Factors . . . . .	91
4.4.2	Inferences from Interdependent Stressors . . . . .	95
4.5	Technology Black Box . . . . .	98
<b>5</b>	<b>Elaborated Life-Testing with Ramp-Stress Tests</b>	<b>101</b>
5.1	Ramp Measurement Methodology . . . . .	102
5.2	Effective Stress Times . . . . .	104
5.3	Validation of Stress-Equivalence . . . . .	115
5.4	Model Fitting with Ramp Tests . . . . .	118
<b>6</b>	<b>Conclusion and Outlook</b>	<b>123</b>
<b>A</b>	<b>Appendix</b>	<b>127</b>
A.1	Auxiliary Transformations and Scalings of the Weibull Distribution . . . . .	127
A.2	Calculation Example for Multi-Dimensional Mission Profiles . . . . .	128
A.3	Process Plans of TDDB Test Devices . . . . .	130
<b>List of Abbreviations</b>		<b>135</b>
<b>Bibliography</b>		<b>137</b>
<b>Publications</b>		<b>147</b>
<b>Acknowledgments</b>		<b>151</b>